



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Ilya Karpov et al.

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Art Unit: 2814

Serial No.: 10/822,361

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Examiner: Long Pham

Filed: April 12, 2004

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Docket: ITL.0835D1US
P14730D

For: Fabricating Deeper and Shallower
Trenches in Semiconductor Structures

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Assignee: Intel Corporation

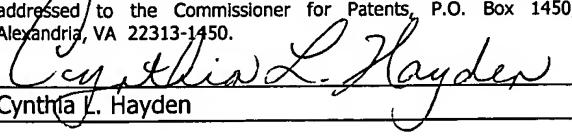
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Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

Prior to the receipt of an office action, please amend the above-referenced patent application as follows:

Date of Deposit: August 26, 2005
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.
 Cynthia L. Hayden